

CORRECTION

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Correction: A scalable twin surface dielectric barrier discharge system for pollution remediation at high gas flow rates

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Correction for 'A scalable twin surface dielectric barrier discharge system for pollution remediation at high gas flow rates' by Alexander Bøddecker *et al.*, *React. Chem. Eng.*, 2022, **7**, 2348–2358, <https://doi.org/10.1039/D2RE00167E>.

The Royal Society of Chemistry regrets that several incorrect symbols were used within the manuscript. Specifically, in Section 3.2, in the section beginning with the sentence "The highest relative conversion of (30.3...", + was inserted in place of ± in several instances.

The corrected section is as shown below:

The highest relative conversion of (30.3 ± 0.5)% can be seen at (153.1 ± 6.7) J L⁻¹ and (162.6 ± 7.1) slm. At higher gas flows the *n*-butane mass flow had to be increased for maintaining the same concentration which means that the relative conversion is decreasing, because there are more molecules to convert. For a comparison Schücke *et al.*²¹ reached a maximum conversion of (46.20 ± 3.75)% of 50 ppm of *n*-butane for an energy density of 423 J L⁻¹.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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